Quantitative topographic imaging using a near-field scanning microwave microscope

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We describe a technique for extracting topographic information using a scanning near-field microwave microscope. By monitoring the shift of the system’s resonant frequency, we obtain quantitative topographic images of uniformly conducting metal surfaces. At a frequency of 9.572 GHz, our technique allows a height discrimination of about 55 nm at a separation of 30 μm. We present topographic images of uneven, conducting samples and compare the height response and sensitivity of the system with theoretical expectations. © 1998 American Institute of Physics.

Images obtained from resonant near-field scanning microwave microscopes 1–5 are the result of two distinct contrast mechanisms: shifts in the resonant frequency due to electrical coupling between the probe and the sample and changes in the quality factor Q of the resonator due to losses in the sample. 3,5 Such images will inevitably contain intrinsic information about a sample (such as dielectric constant or surface resistance) 5 as well as extrinsic information (such as surface topography). To facilitate quantitative imaging of intrinsic material properties, it is essential to be able to accurately account for the effects of finite probe–sample separation and topography. 6,7 In this letter, we report on the extraction of calibrated topographic images using a resonant near-field scanning microwave microscope.

Our near-field scanning microwave microscope is based on an open-ended transmission line resonator of length L = 1 m and characteristic impedance Z₀ = 50 Ω. 8,9 One end of the transmission line is connected to a fine open-ended coaxial probe positioned at a distance h above the sample, while the other end is weakly coupled through capacitance C_d to a directional coupler and a frequency modulated microwave source V_s (see Fig. 1). A frequency-following circuit is used to monitor the resonant frequency of the transmission line. 9 In this technique, the microwave source frequency is modulated by ±3 MHz at a rate of f_FM = 3 kHz. The voltage reflected from the resonant cable is monitored by a diode at the output of the directional coupler. The diode output is fed to a lock-in amplifier, which is referenced at the oscillator frequency f_FM. The output voltage of the lock-in amplifier is integrated and the resulting voltage V FM is utilized to keep the source locked to a specific standing wave resonance f_n of the transmission line. In this configuration, V_FM is directly proportional to changes in f_n, caused by changes in coupling to the sample. In practice, we record V_FM as a function of the position of the sample beneath the probe, thereby constructing a map of frequency shift versus position.

The interaction between the probe and a metallic sample can be represented by a capacitance C_p between the sample and the inner conductor of the probe, analogous to the mechanism in scanning capacitance microscopy. 8,10,11 For a highly conducting sample and a small probe–sample capacitance C_p, i.e., C_p ≪ L/c Z₀, the reflected voltage V_r at the output of the directional coupler can be written as

\[ |V_r| = \left| \frac{Z_a - Z_0}{Z_a + Z_0} \right| P(1 - P)V_s, \tag{1} \]

where

\[ Z_a = \frac{1}{i \omega C_d} + \frac{Z_0 \left( \cosh(\gamma L) + i \omega C_p Z_0 \sinh(\gamma L) \right)}{\sinh(\gamma L) + i \omega C_p Z_0 \cosh(\gamma L)}, \tag{2} \]

and where c is the speed of light, ω is the angular frequency of the source, γ is the propagation constant for the transmission line, and P is the coupling factor of the directional coupler. A plot of Eq. (1) versus frequency would show a series of dips corresponding to enhanced absorption at the resonant frequencies. For C_p = 0 and C_d = 0, the resonant

\[ \text{FIG. 1. Schematic of the experimental setup and an uneven, uniformly conducting sample. Variation in probe–sample separation h produces a shift of the coaxial transmission line resonant frequency which is tracked by the frequency-following circuit.} \]

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frequencies are \( f_n = n c / (2 \varepsilon_r L) \), for \( n = 1, 2, \ldots \), where \( \varepsilon_r \) is the dielectric constant of the transmission line; for our system a resonance occurs every 125 MHz. For small \( C_x \), the nth resonant frequency changes by 10 MHz. The darker colored regions in Fig. 3 indicate a smaller frequency shift from the probe than the lighter regions (smaller frequency shift). We next measured the frequency shift versus height at a fixed position above a flat part of the sample (see Fig. 2) and determined the transfer function \( h(\Delta f) \). Using \( h(\Delta f) \), we then transformed the frequency shift image into a topographic surface plot [see Fig. 3(b)].

To determine the absolute accuracy of the height in the topographic image, we optically measured the height of several prominent features on the coin. In Fig. 4, the solid line represents a plot of height versus position as determined by the microwave microscope for a slice taken through the center of the coin [see the arrows in Fig. 3(a)] while the open circles show the optically measured points. Corresponding points in the two data sets typically differ by about 13 \( \mu \)m. The accuracy at large separation is limited by the drift of the source frequency, and can be optimized by measuring the calibration curve immediately after the scan.12

To determine the height precision, the scan data at the...
left rim in Fig. 4 were fit to a parabola (over a range of \( x = \pm 500 \mu m \)) and the standard deviation was found to be 55 nm for a probe–sample separation of 30 \( \mu m \). Similarly, for the flat area on the table just to the right of the coin, a linear fit was performed to the data (over a range of \( x = \pm 500 \mu m \)) and yielded a standard deviation of 40 \( \mu m \) at a probe–sample separation of 1.75 mm. In our system, the predominant source of noise is fluctuations \( \delta(\Delta f) \) in the source frequency. In this case, the smallest detectable change in height is expected to be

\[
\Delta h = \frac{\partial h}{\partial \Delta f} \delta(\Delta f).
\]

For a source frequency fluctuation of 10 kHz and a value for the height transfer function of 41 \( \mu m/MHz \) we find that the theoretical height sensitivity at a probe–sample separation of 30 \( \mu m \) is approximately 41 nm, in reasonable agreement with the measured value.

In summary, we have used an open-ended resonant near-field scanning microwave microscope to obtain quantitative topographic images of a metallic surface. As a result, we can quantitatively account for the contribution of topography to frequency shift images. Our technique allows a height resolution of 55 nm a 30 \( \mu m \) probe–sample separation and about 40 \( \mu m \) at a separation of 1.75 mm. The technique is simple and should be readily extendible to nonmetallic samples, smaller probes, and closer or farther separations.

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12. A source frequency drift effectively translates the calibration curve along the \( -\Delta f \) axis, and can be corrected by checking the frequency shift at a known height. In this case we used a probe–table separation of 1.75 mm.